

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	55	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) same ((adjust or adjusting or adjustment or optimization or optimizing or optimized or changing or selecting or selection or selected or configuring or altering or alteration or altered) near3 (roughness))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 08:37
L2	145	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) and (leveler or leveling or levelling or leveller) near3 (amount or concentration or wt) and (cmp or planarization or planarizing or polishing or planarized)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 08:51
L3	67	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) near10 (copper or cu or metal) and (roughness or roughened or smoothness or rough or roughening or height near difference) near (rms or nm or nanometer or ang or angstrom)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 09:05
L4	307	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) and (leveler or leveller or levelling or leveling or brightener or additive) near2 (roughness or texture or rough or roughened or texturing or grain or granularity)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 10:59
L5	2	(chemical adj mechanical adj polishing or cmp) near5 (roughness or roughened or rough or roughening or rms or texture or textured or texturing) near10 (endpoint or end adj point or ending or stop or stopping)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 11:00
L6	14	(chemical adj mechanical adj polishing or cmp) near15 (roughness or roughened or rough or roughening or rms or texture or textured or texturing) near15 (endpoint or end adj point or ending or stop or stopping or end)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 11:14
L7	270	(chemical adj mechanical adj polishing or cmp) near15 (roughness or roughened or rough or roughening or rms or texture or textured or texturizing or texturing) near3 (adjusting or adjustment or adjusted or selection or selecting or selected or choosing or chosen or chose or configured or configuration or configuring or high or large or increasing or increased or increase or greater or larger or higher)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 11:15
L8	25	(chemical adj mechanical adj polishing or cmp) near15 (roughness or roughened or rough or roughening or rms or texture or textured or texturizing or texturing) near3 (adjusting or adjustment or adjusted or selection or selecting or selected or choosing or chosen or chose or configured or configuration or configuring or high or large or increasing or increased or increase or greater or larger or higher) same (metal or electrolyte or electrolytic or electro-plating or electroplating or electro-plated or electroplated or metallic)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 11:16
L9	31	(chemical adj mechanical adj polishing or cmp) near15 (roughness or roughened or rough or roughening or rms or texture or textured or texturizing or texturing) near3 (adjusting or adjustment or adjusted or selection or selecting or selected or choosing or chosen or chose or configured or configuration or configuring or high or large or increasing or increased or increase or greater or larger or higher) same (metal or electrolyte or electrolytic or electro-plating or electroplating or electro-plated or electroplated or metallic or copper or cu or nickel or ni or gold or au or platinum or pt or tantalum or ta or titanium or ti or tungsten or w)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 11:57
L10	99	438/8.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 12:45

L11	13	438/500.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 12:46
L12	33	438/502.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 13:03
L13	443	438/618.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 13:04
L14	319	438/618.ccor. and (cmp or planarization or planarizing or planarized or polishing or polished)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 13:24
L15	53	438/620.ccor. and (cmp or planarization or planarizing or planarized or polishing or polished)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 13:28
L17	588	438/622.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 13:29
L18	51	438/622.ccor. and (smoothness or smoothened or roughness or rough or roughening or roughened or rms)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 13:32
L19	30	438/626.ccor. and (smoothness or smoothened or roughness or rough or roughening or roughened or rms)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 13:36
L20	9	438/631.ccor. and (smoothness or smoothened or roughness or rough or roughening or roughened or rms)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 13:38
L21	32	438/633.ccor. and (smoothness or smoothened or roughness or rough or roughening or roughened or rms)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 13:39
L22	10	438/638.ccor. and (smoothness or smoothened or roughness or rough or roughening or roughened or rms)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 13:45
L23	125	438/631.ccor.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 13:45
L24	51	438/687.ccor. and (smoothness or smoothened or roughness or rough or roughening or roughened or rms)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 13:59

L25	199	438/692.ccor. and (smoothness or smoothened or roughness or rough or roughening or roughened or rms)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 13:59
S7	51	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) same ((adjust or adjusting or adjustment or optimization or optimizing or optimized or changing or selecting or selection or selected or configuring or altering or alteration or altered) near3 (roughness))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 08:37
S10	124	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) and (leveler or leveling or levelling or leveller) near3 (amount or concentration or wt) and (cmp or planarization or planarizing or polishing or planarized)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 08:51
S13	60	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) near10 (copper or cu or metal) and (roughness or roughened or smoothness or rough or roughening or height near difference) near (rms or nm or nanometer or ang or angstrom)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 09:05
S18	297	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) and (leveler or leveller or levelling or leveling or brightener or additive) near2 (roughness or texture or rough or roughened or texturing or grain or granularity)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 10:28